



Quantification in X-ray fluorescence analysis and the contribution of Monte Carlo simulations

Mateusz Czyzycki, Pawel Wrobel, Dariusz Wegrzynek
and Marek Lankosz

Outline

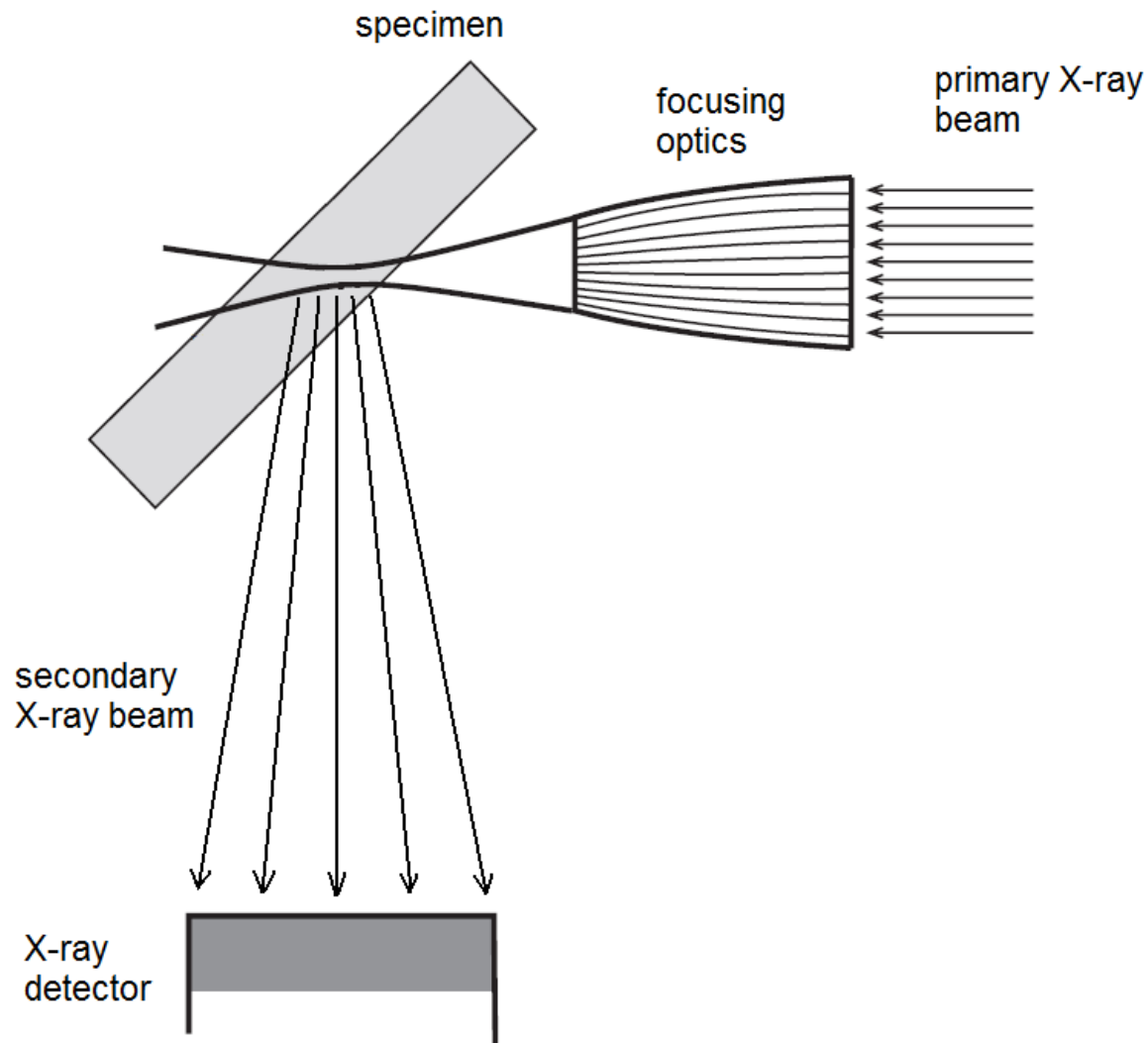
- > Confocal XRF spectroscopy in tilted geometry
- > Fundamental Parameters model
- > Monte Carlo simulations
- > Examples
 - Multi-layers with low-Z matrices,
 - Multi-layers of alloys.

Multi-layer materials

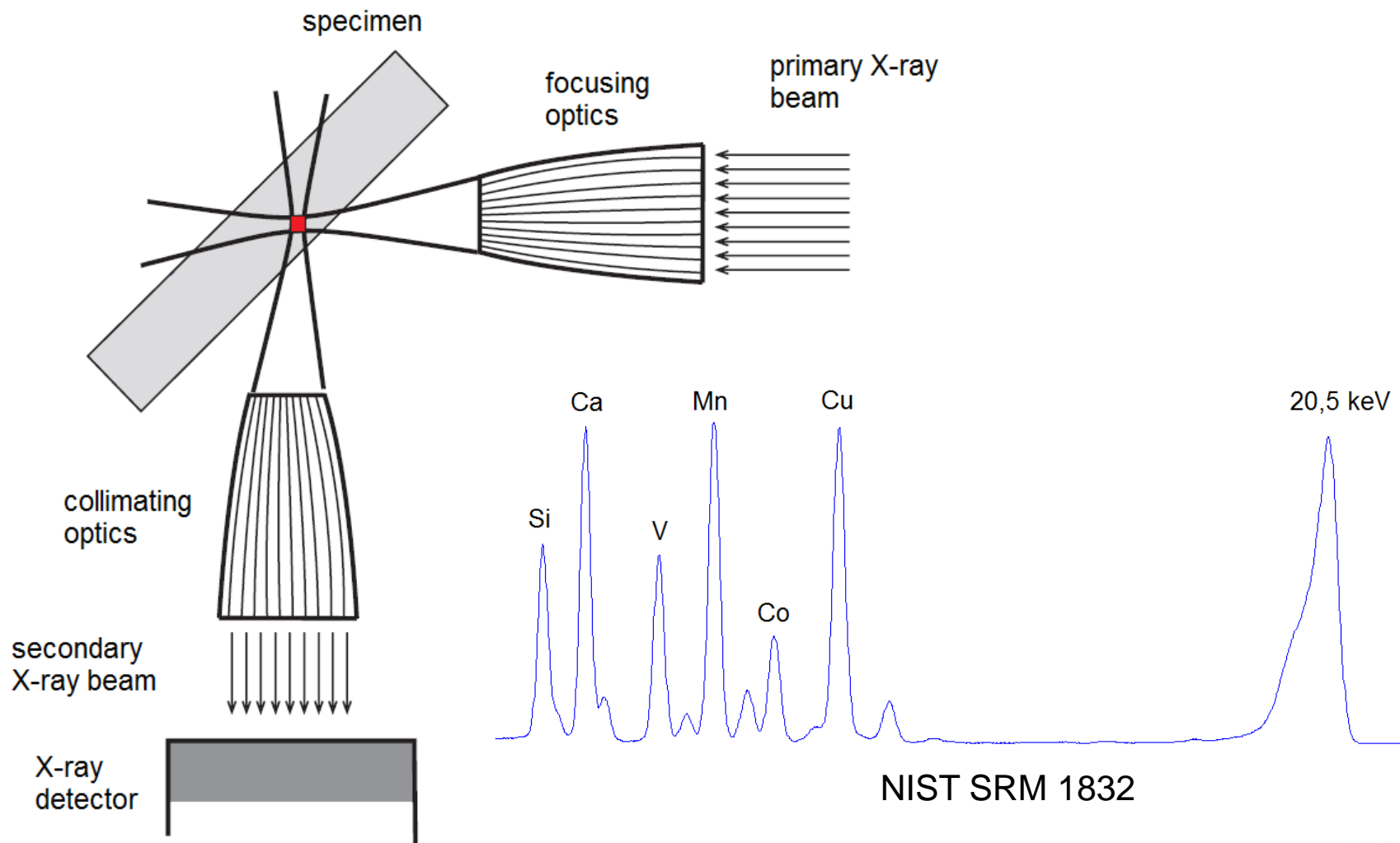
- > electronics
- > energy production & storage
- > optics
- > environmental solutions
- > petroleum industry
- > automotive industry
- > building industry
- > biomedical applications

- > **cultural heritage**

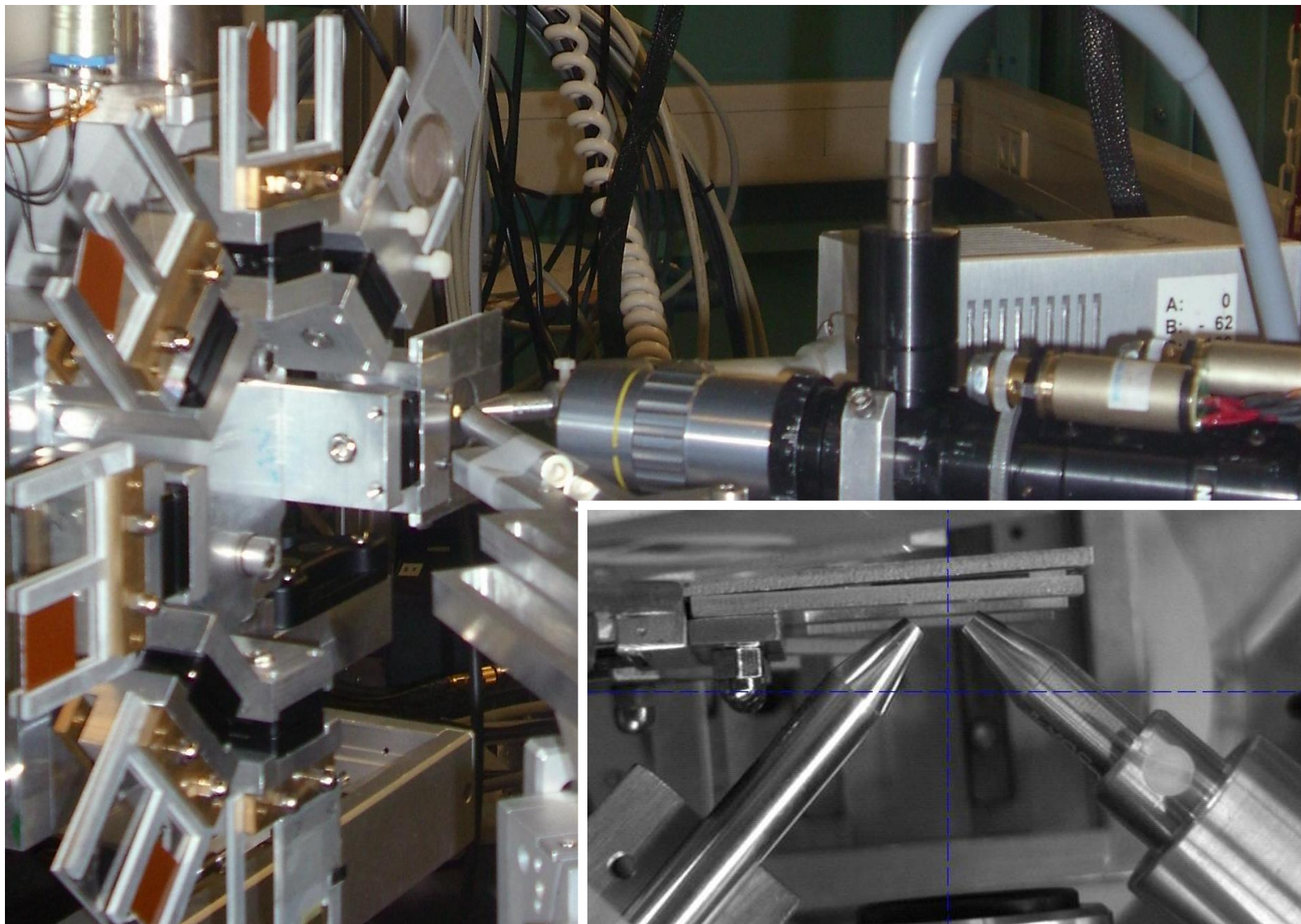
Conventional geometry



Confocal geometry

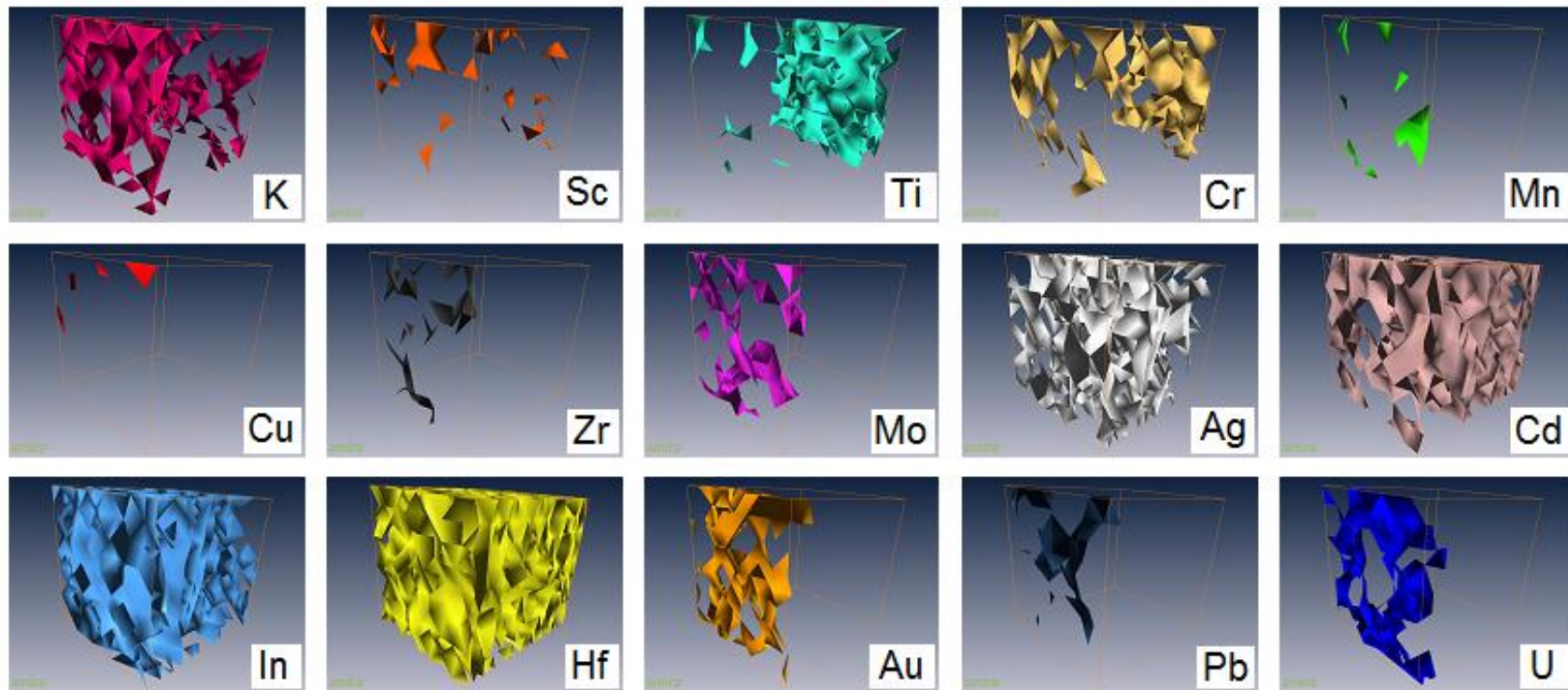


Experimental endstation



Mateusz Czyzycki *et. al.*, Joint ICTP-IAEA Workshop on Advances in X-ray Instrumentation for Cultural Heritage Applications, 13-17 July 2015, Trieste, Italy

NIST SRM 611



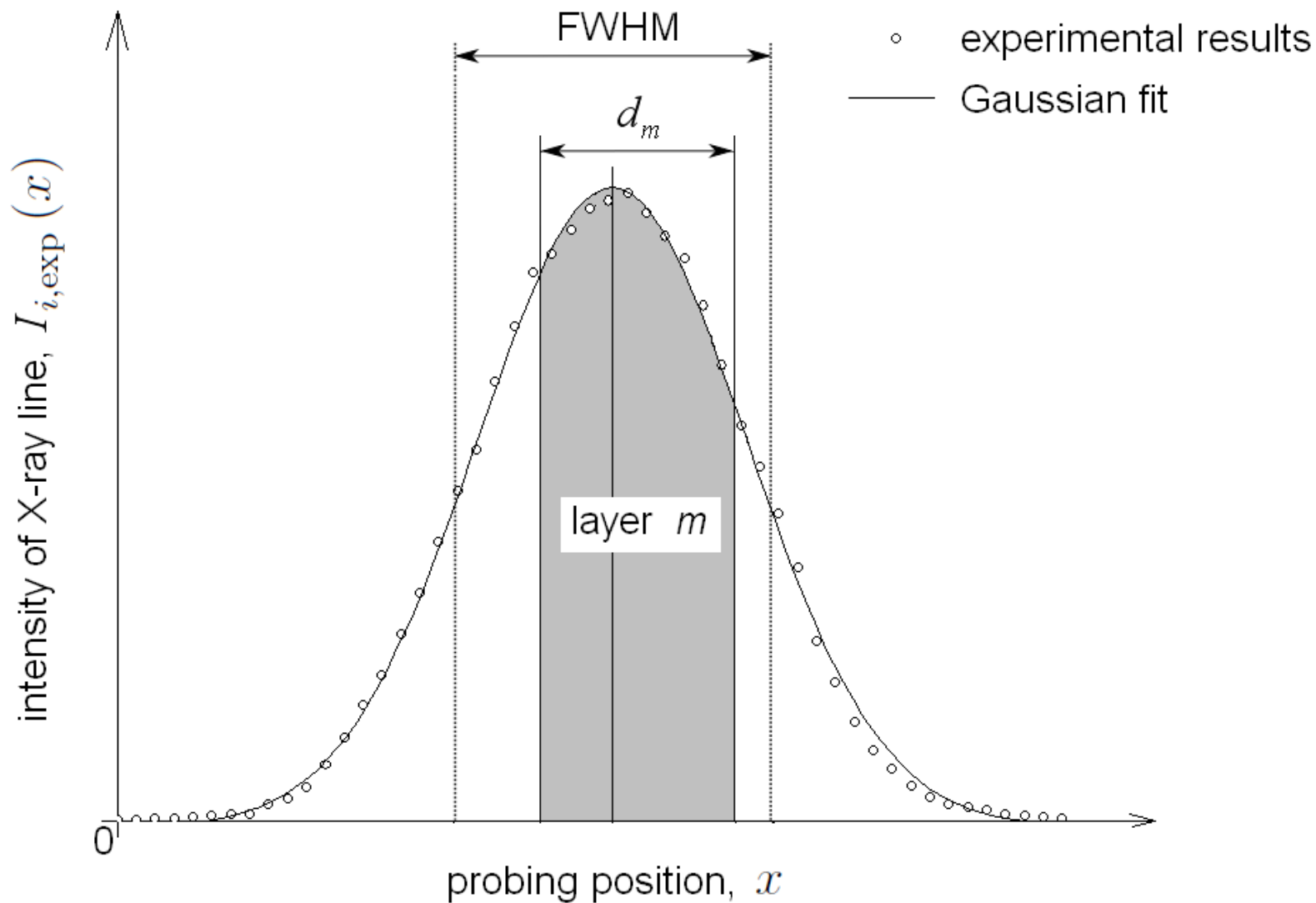
HASYLAB, DESY, DORIS III, beamline L

NIST SRM 611 glass standard. Scanned volume: 135 μm / 135 μm / 150 μm

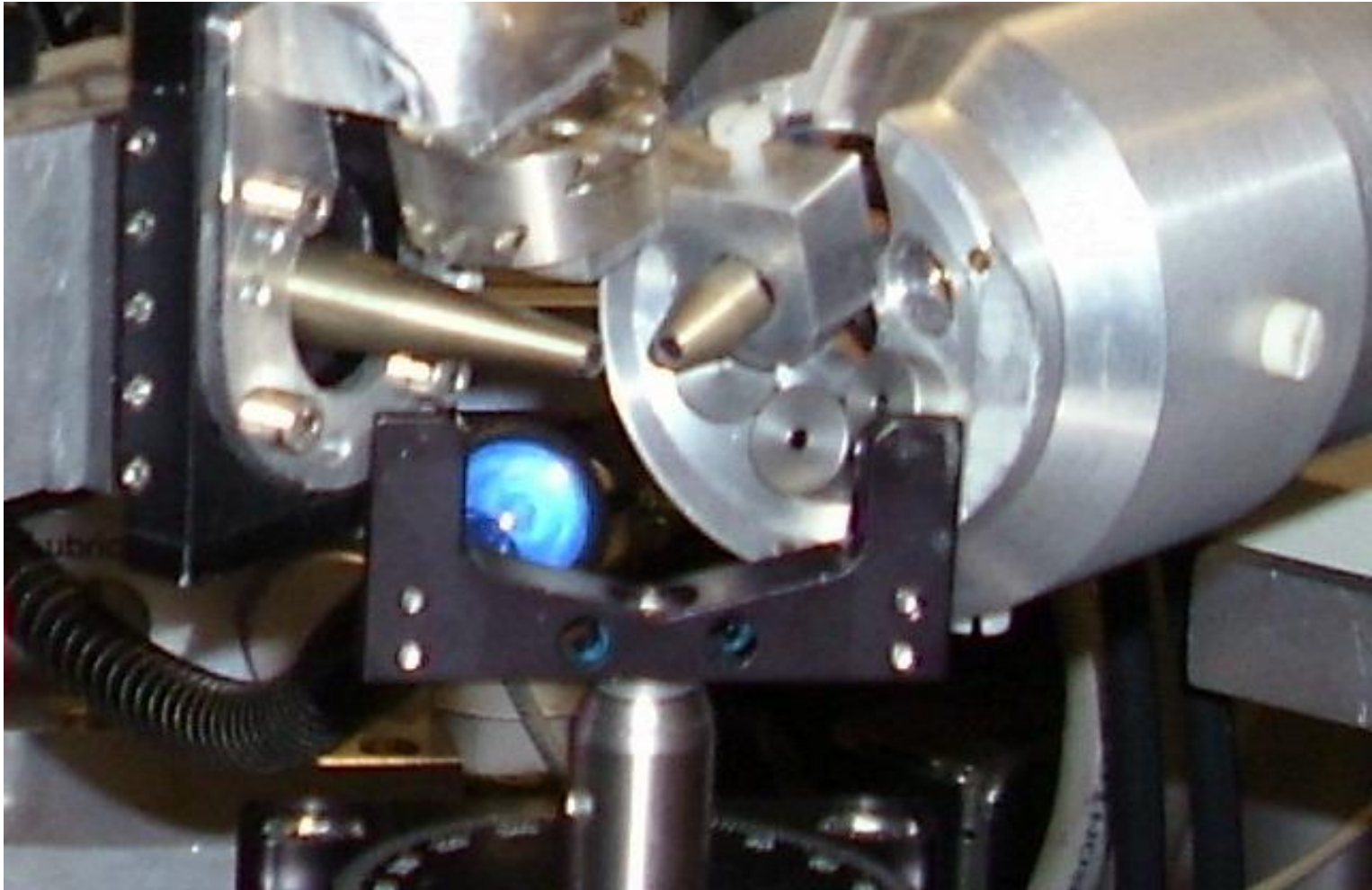
Incident X-ray beam: 6.7 μm , 21 keV.

M. Czyzycki et al., unpublished work

Confocal experiment on a single layer

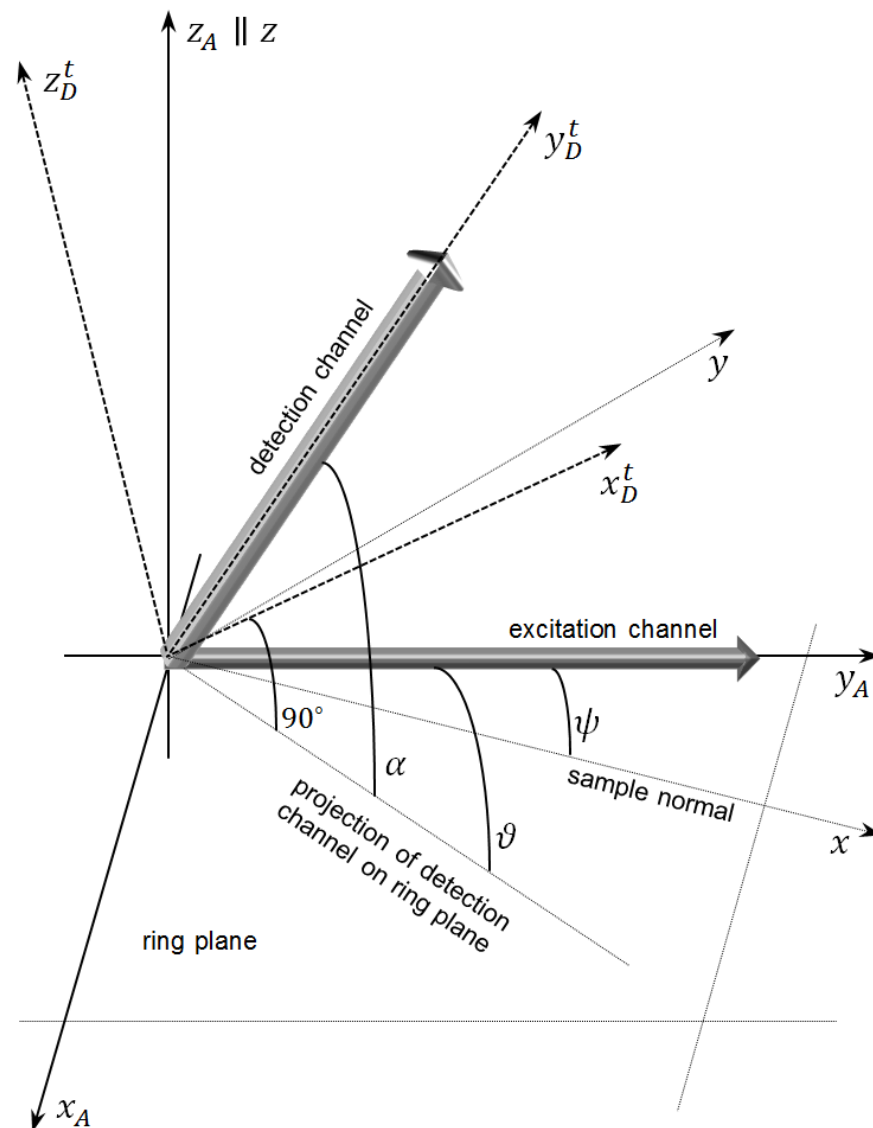


Equipment in tilted geometry



Mateusz Czyzycki *et. al.*, Joint ICTP-IAEA Workshop on Advances in X-ray Instrumentation for Cultural Heritage Applications, 13-17 July 2015, Trieste, Italy

Tilted geometry – schematic drawing



Fundamental parameter model – general

$$\eta_A(\vec{r}_A) = \frac{T_A}{2\pi\sigma_A^2} \exp\left(-\frac{x_A^2 + z_A^2}{2\sigma_A^2}\right)$$

$$\eta_D(\vec{r}_D^t) = \frac{\Omega}{4\pi} T_D \varepsilon \exp\left(-\frac{(x_D^t)^2 + (z_A^t)^2}{2\sigma_D^2}\right)$$

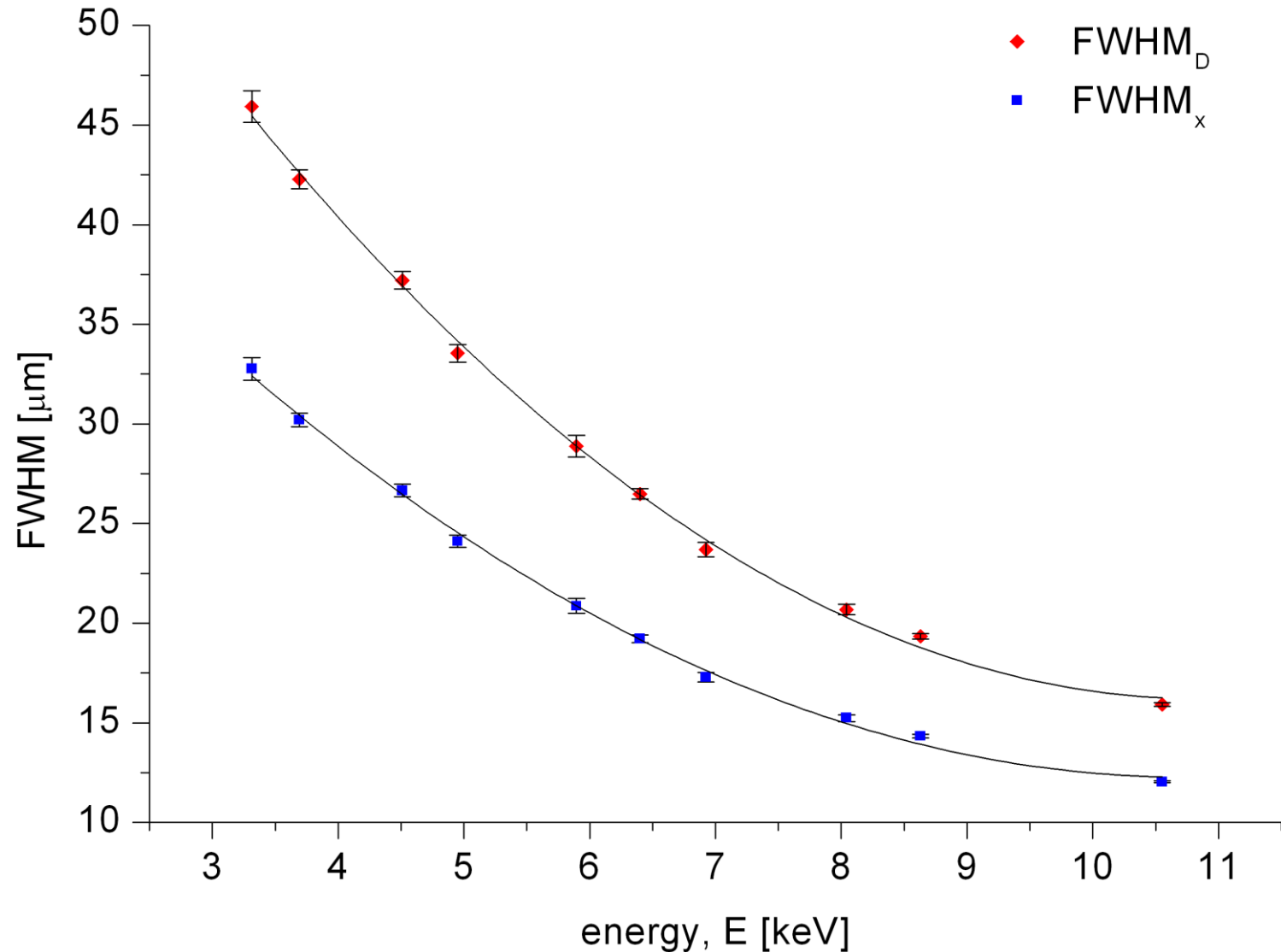
$$\eta(\vec{r}_A) = \eta_A(\vec{r}_A) \cdot \eta_D(\vec{r}_A)$$

$$\tilde{\eta} = \int_{-\infty}^{\infty} \int_{-\infty}^{\infty} \int_{-\infty}^{\infty} \eta(\vec{r}_A) dx_A dy_A dz_A = \frac{T_A T_D \Omega \varepsilon}{\sqrt{8\pi}} \frac{\sigma_D^2}{\sqrt{\sigma_A^2 + \sigma_D^2}}$$

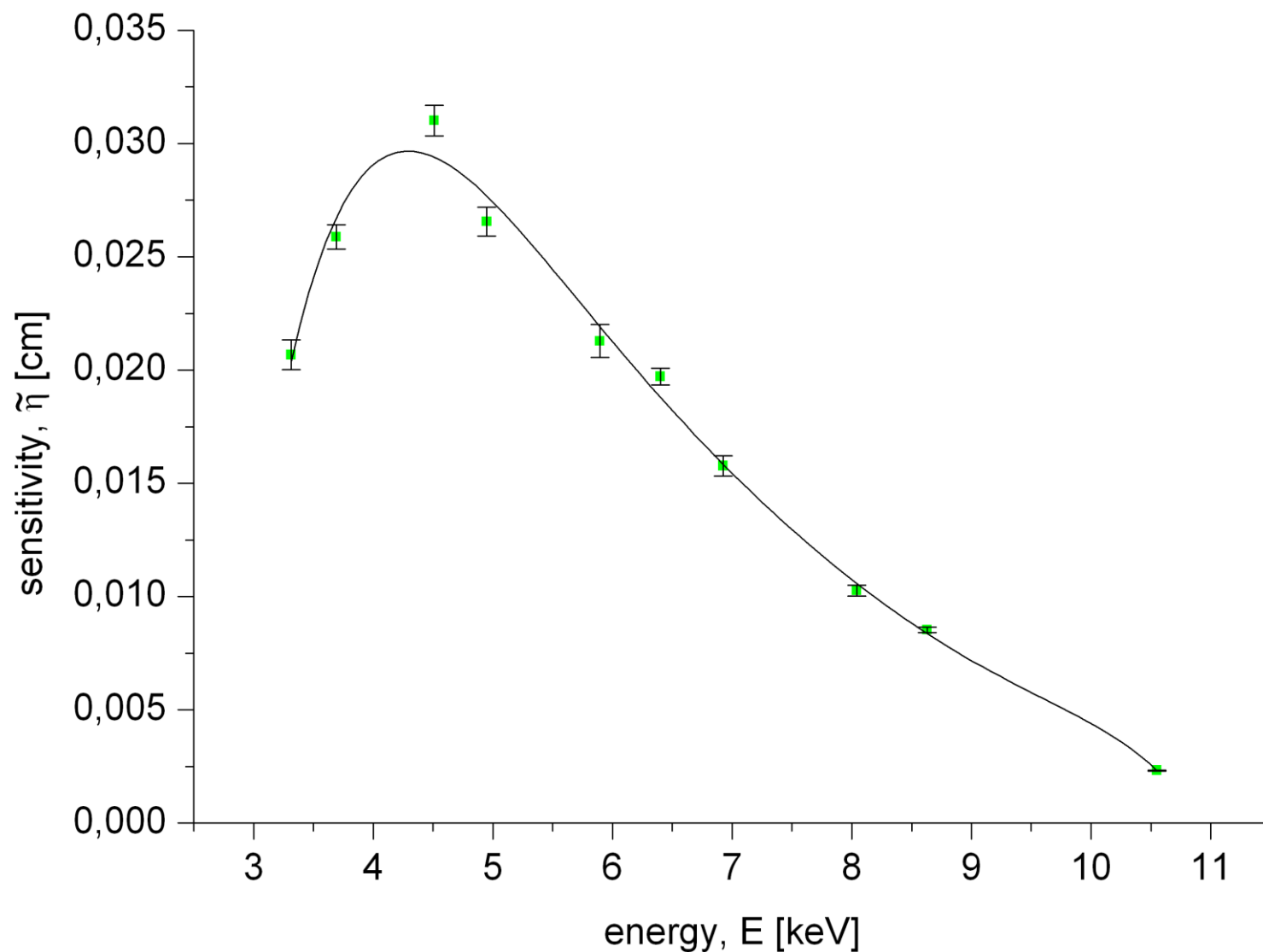
$$\eta_x(x) = \int_{-\infty}^{\infty} \int_{-\infty}^{\infty} \eta(\vec{r}) dy dz = \frac{\tilde{\eta}}{\sqrt{2\pi}\sigma_x} \exp\left(-\frac{x^2}{2\sigma_x^2}\right)$$

W. Malzer, B. Kanngiesser, *Spectrochim. Acta Part B* 2005; 60, 1334-1341

Spatial resolution in confocal geometry



Integral sensitivity



Fundamental parameter model – in tilted geometry

$$\sigma_x = \sqrt{\chi \sigma_A^2 \sin^2 \psi + \sigma_D^2 \cos^2 \psi}$$

$$\chi = \frac{\sigma_A^2 \cos^2 \alpha + \sigma_D^2}{\sigma_A^2 + \sigma_D^2}$$

$$\Phi_l(x) = \Phi_0 \sigma_F \int_0^D \eta_x(\zeta - x) \rho(\zeta) \exp \left[- \int_0^\zeta \mu_{\text{lin}}(\xi) d\xi \right] d\zeta$$

$$\mu_{\text{lin}} = \sum_i \rho_i \left(\frac{\mu_{0,i}}{\cos \vartheta_A} + \frac{\mu_{j,i}}{\cos \alpha \cos \vartheta_D} \right)$$

M. Czyzycki, P. Wrobel, M. Lankosz, *Spectrochim. Acta Part B* 2014; 97, 99-104

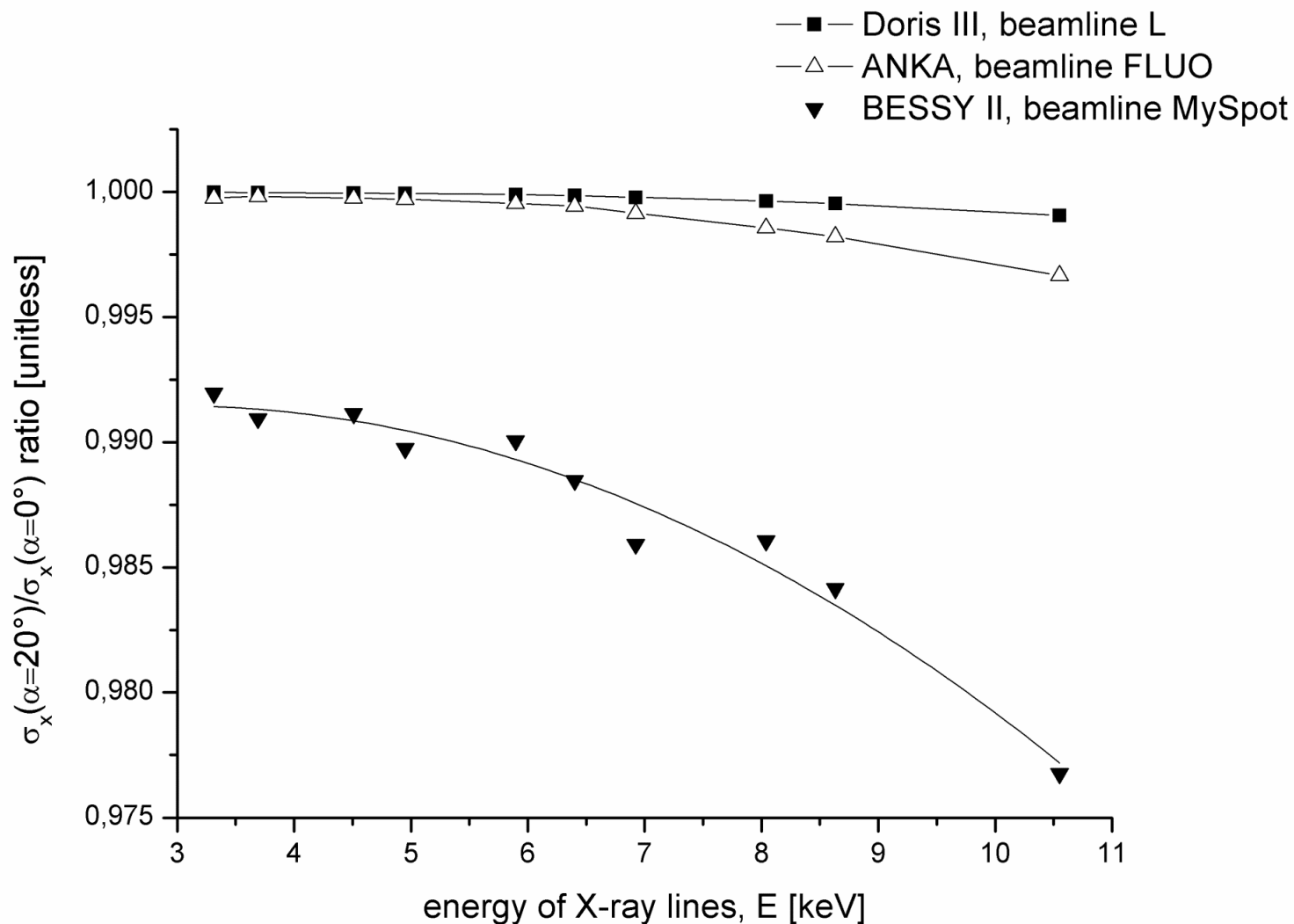
Fundamental parameter model

$$\Phi_l(x) = \frac{\Phi_0 \tilde{\eta} \sigma_F \rho}{2} \exp(-\mu_{\text{lin}} x) \exp\left(\frac{(\mu_{\text{lin}} \sigma_x)^2}{2}\right) \\ \times \left\{ \operatorname{erf}\left(\frac{D + \mu_{\text{lin}} \sigma_x^2 - x}{\sqrt{2} \sigma_x}\right) - \operatorname{erf}\left(\frac{\mu_{\text{lin}} \sigma_x^2 - x}{\sqrt{2} \sigma_x}\right) \right\}$$

$$\Phi(x) = \sum_{l=1}^n \Phi_l(x) \prod_{k=1}^{l-1} \exp(-\mu_{\text{lin},k} D_k)$$

I. Mantouvalou, W. Malzer, I. Schaumann, L. Lühl, R. Dargel, C. Vogt, B. Kanngiesser, *Anal. Chem.* 2008; 80, 819-826

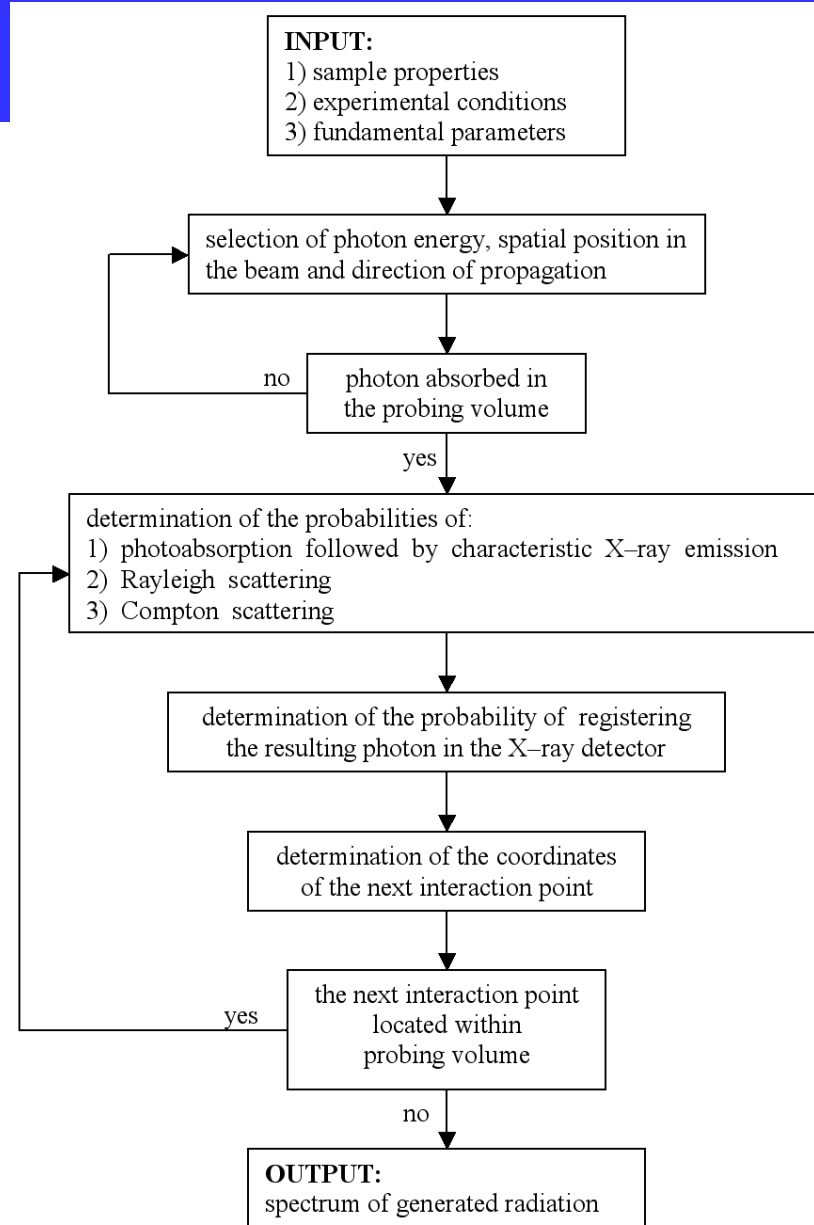
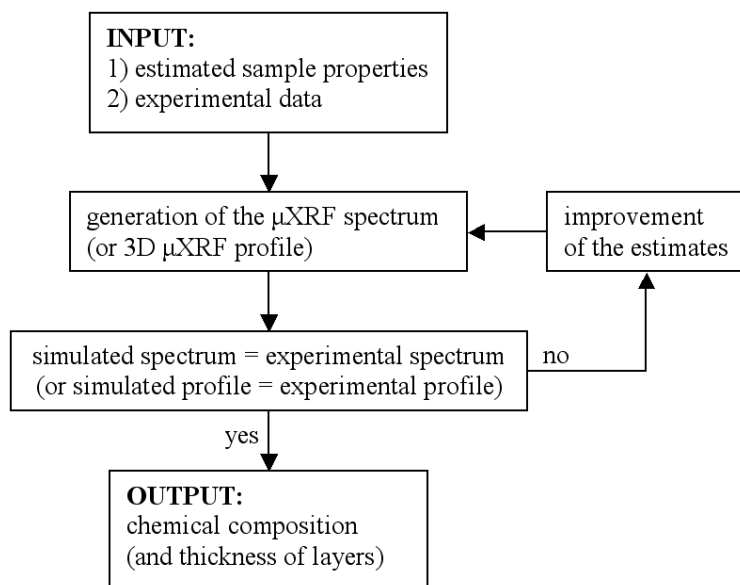
Spatial resolution in tilted geometry



Monte Carlo simulation – Why to use?

1. Morphology of the sample:
shape, sizes, inner structure, inhomogeneities, layers
2. Experimental conditions:
spectral and spatial distribution of X-ray beam, polarisation effects,
unlimited geometries
3. Interaction of X-rays with matter:
photoabsorption, scattering effects

Monte Carlo algorithm



Quantitative reconstruction of layers

Element concentrations:

$$w_i^{(k+1)}(x) = w_i^{(k)}(x) \frac{Y_{i,\text{exp}}(x)}{Y_{i,\text{MC}}^{(k)}(x) \sum_{j=1}^{N_m} w_j^{(k)}(x) \frac{Y_{j,\text{exp}}(x)}{Y_{j,\text{MC}}^{(k)}(x)}}$$

Thicknesses:

$$d_m^{(k+1)} = \frac{d_m^{(k)}}{N_x N_X} \sum_x \sum_{i=1}^{N_X} \frac{Y_{i,\text{exp}}(x)}{Y_{i,\text{MC}}^{(k)}(x)}$$

M. Czyzycki, D. Wegrzynek, P. Wrobel, M. Lankosz, *X-Ray Spectrom.* 2011; 40, 88-95

Computing cluster

> **Software**

C, Perl, Unix, *xraylib* library

> **Hardware**

IBM BladeCenter HS21 cluster
112 Intel Dual-core processors
2GB RAM/core
2.4 Tflops

Academic Computer Centre

CYFRONET AGH, Cracow, Poland



Multi-layer Zn standard on polymer matrix

9 individual layers

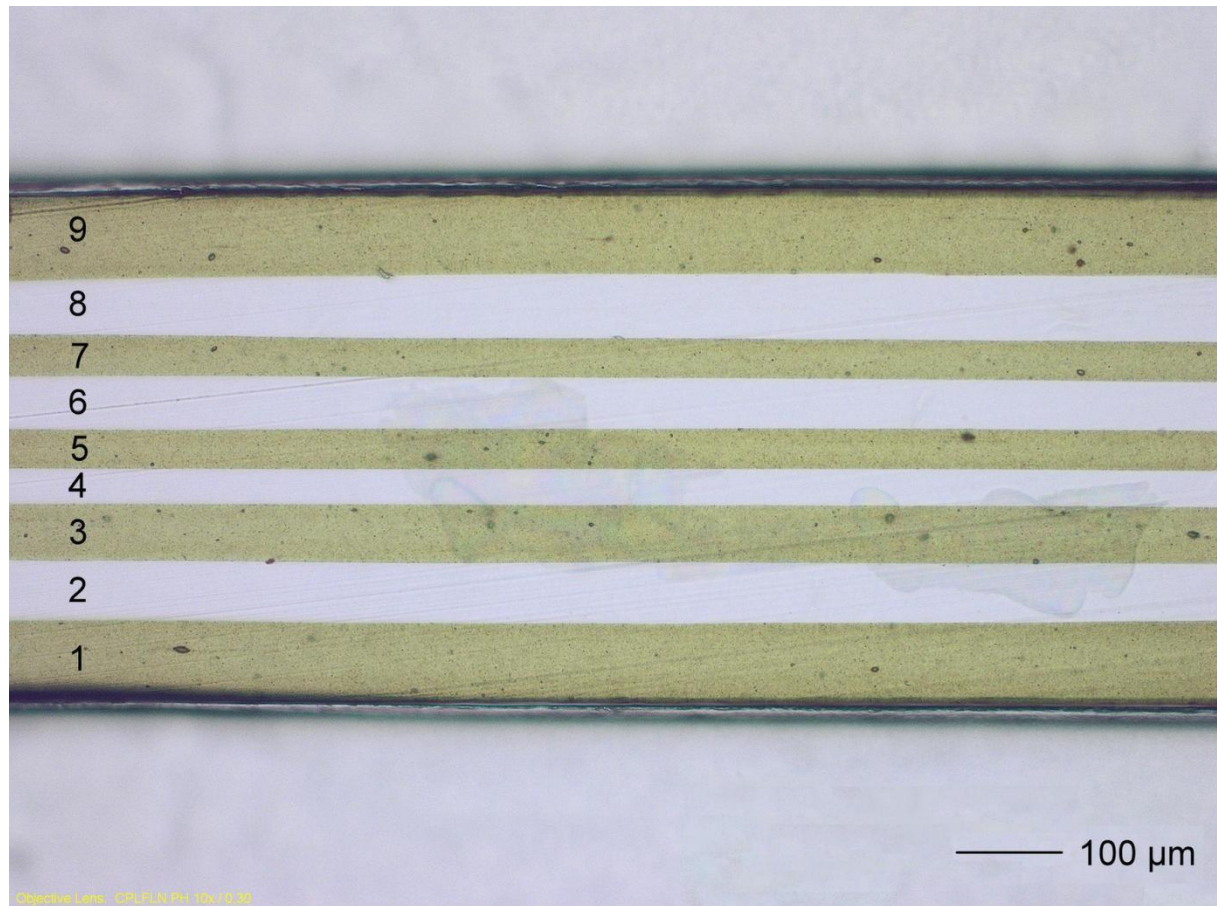
odd layers:

$(\text{CH}_2)_n$ – 95.02%

ZnO – 4.98%

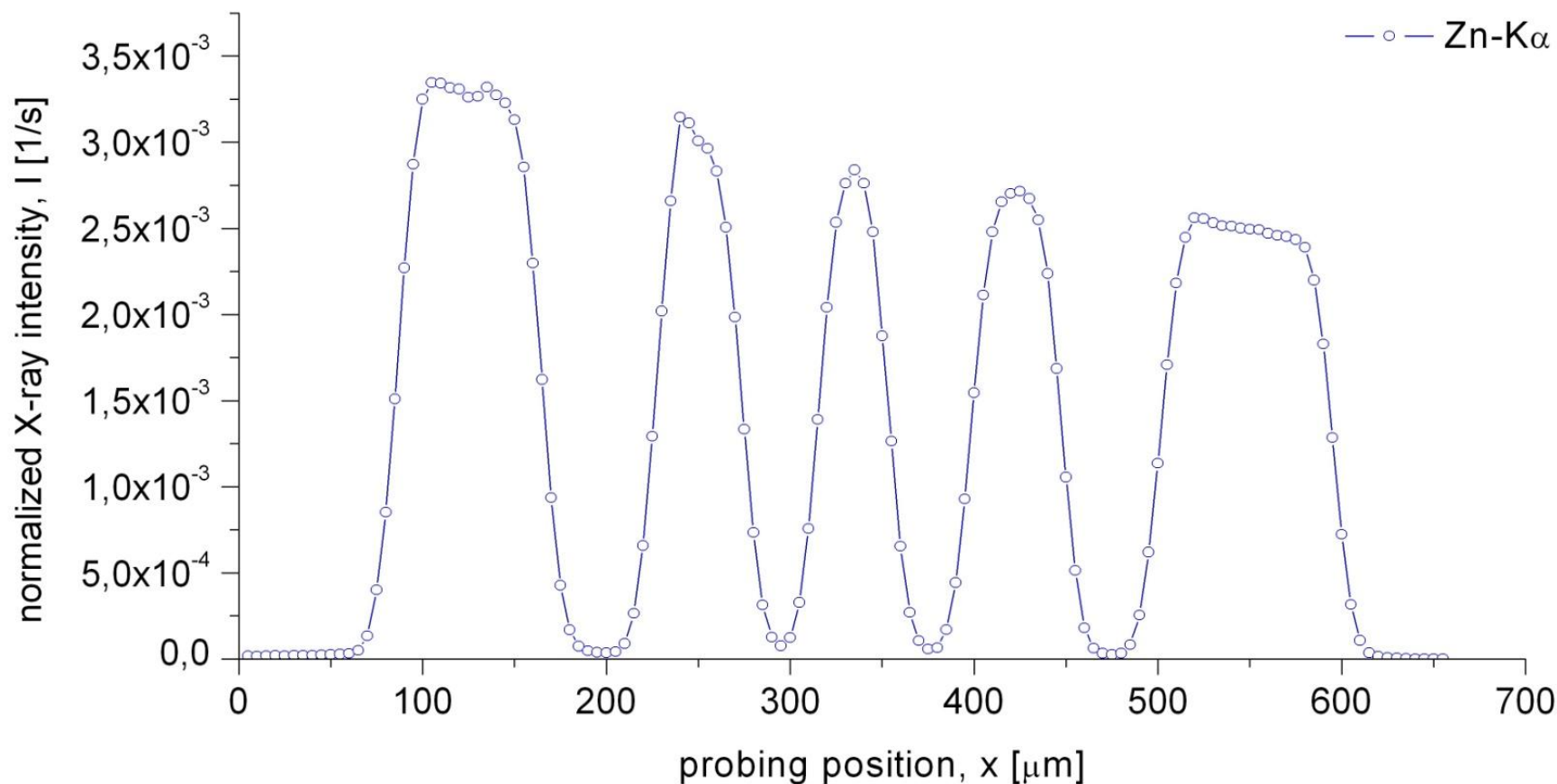
even layers:

$(\text{CH}_2)_n$ – 100%



M. Czyzycki, P. Wrobel, M. Szczerbowska-Boruchowska, B. Ostachowicz, D. Wegrzynek, M. Lankosz, *X-Ray Spectrom.* 2012; 41, 273-278

Depth-sensitive scan on Zn standard



HASYLAB at DESY, DORIS III, beamline L

Spatial resolution in depth-scan: **14.3 μm (Zn-K α)**

Reconstruction of multi-layer Zn standard

Layer no.	ZnO weight fraction determined by MC	Layer thickness	
		MC	Optical microscope
		[μm]	[μm]
1	4.98 (0.07)	80.5 (0.6)	80.2 (0.3)
2		63.2 (0.5)	62.4 (0.4)
3	5.06 (0.06)	45.9 (0.4)	45.3 (0.4)
4		43.8 (0.4)	43.6 (0.5)
5	4.84 (0.15)	38.7 (0.3)	38.8 (0.9)
6		45.9 (0.4)	46.5 (0.6)
7	4.76 (0.07)	49.9 (0.4)	51.3 (1.1)
8		55.0 (0.4)	54.8 (0.5)
9	4.95 (0.05)	96.8 (0.8)	97.3 (0.6)
nominal	4.98		

Multi-layer Zn/Cu standard on polymer matrix

9 individual layers

odd layers:

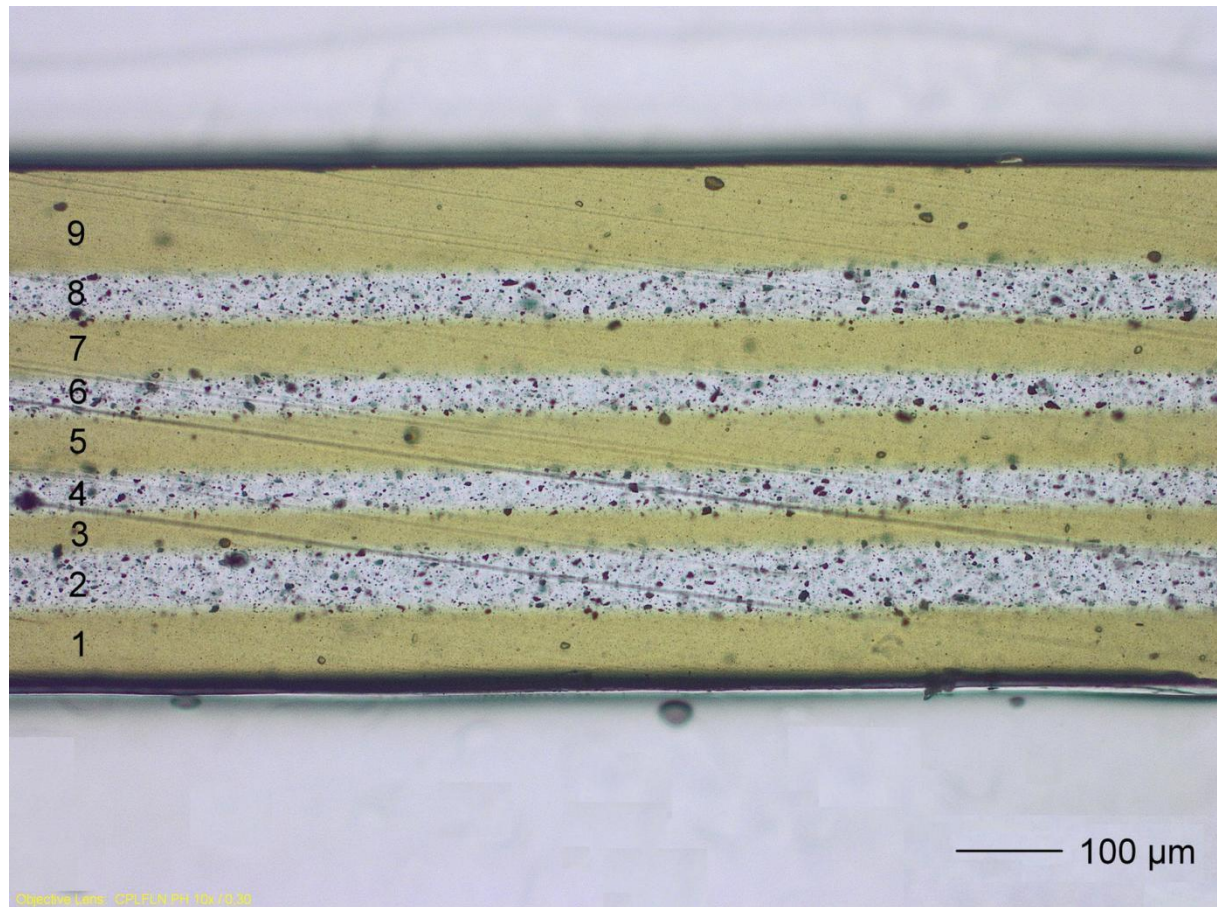
$(\text{CH}_2)_n$ – 95.02%

ZnO – 4.98%

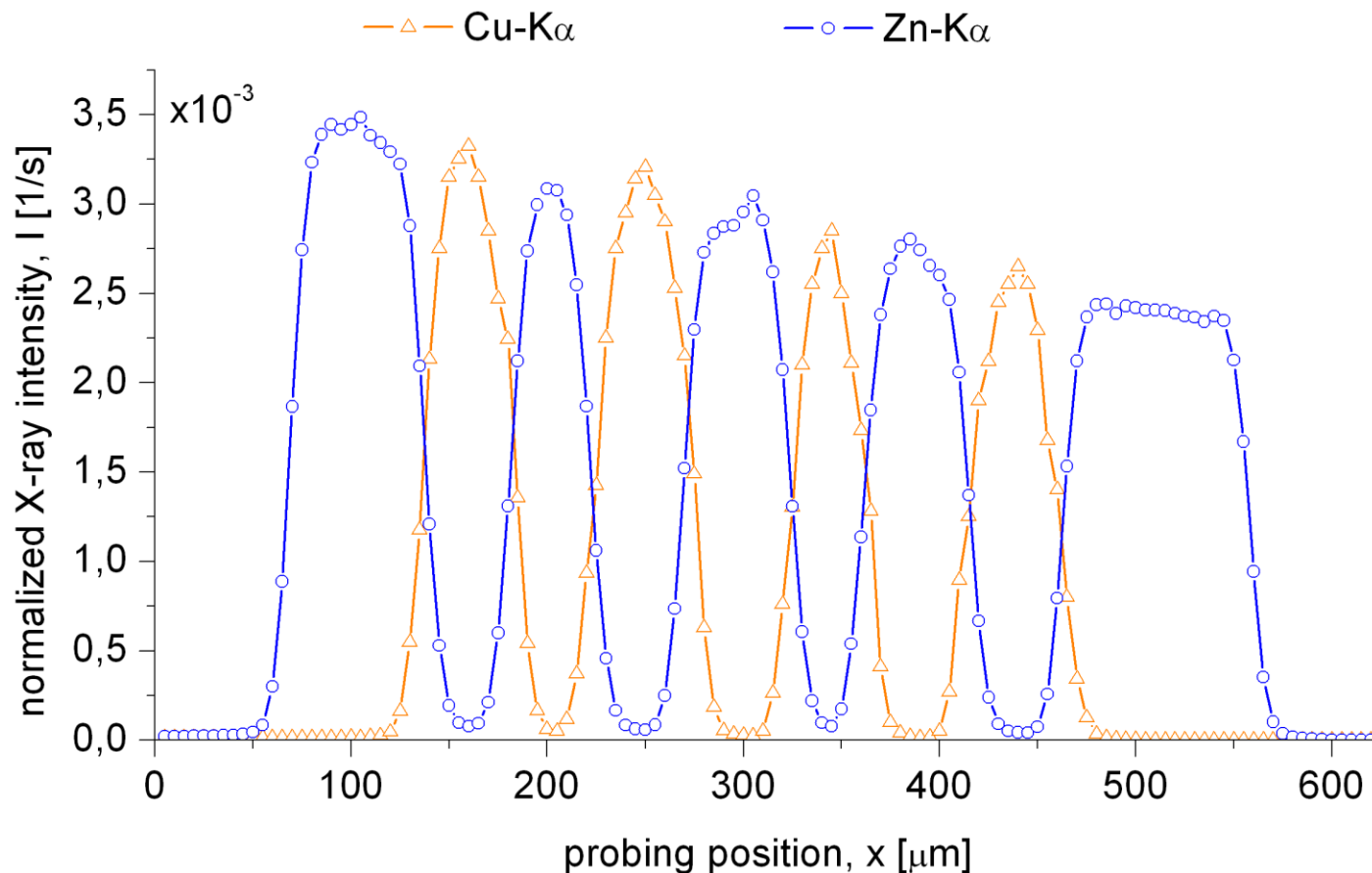
even layers:

Cu_2O – 4.50%

$(\text{CH}_2)_n$ – 95.50%



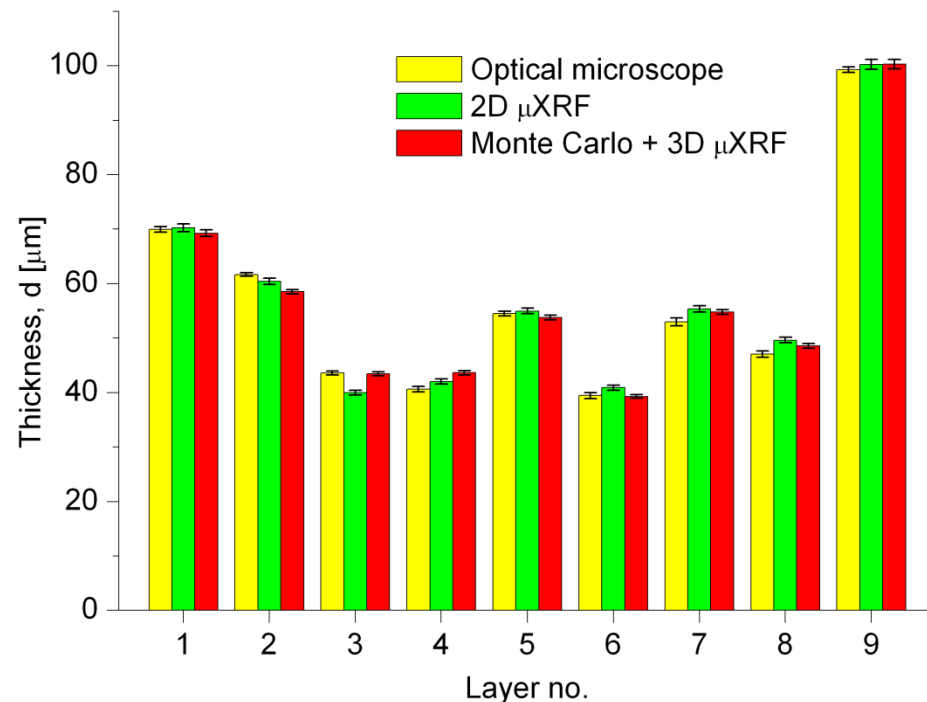
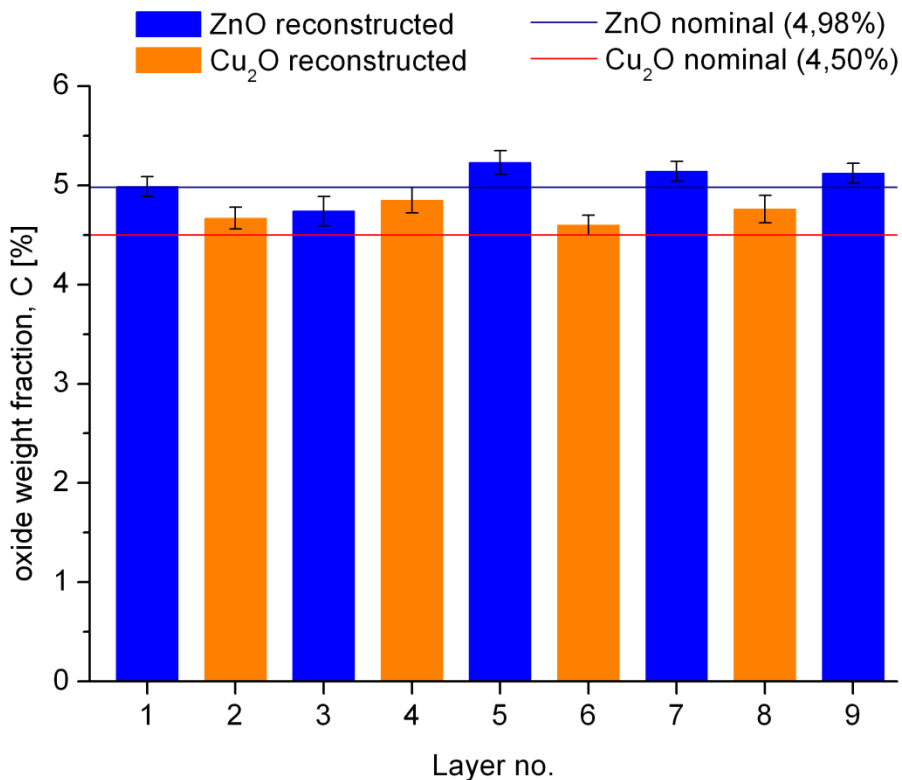
Depth-sensitive scan on Zn/Cu standard



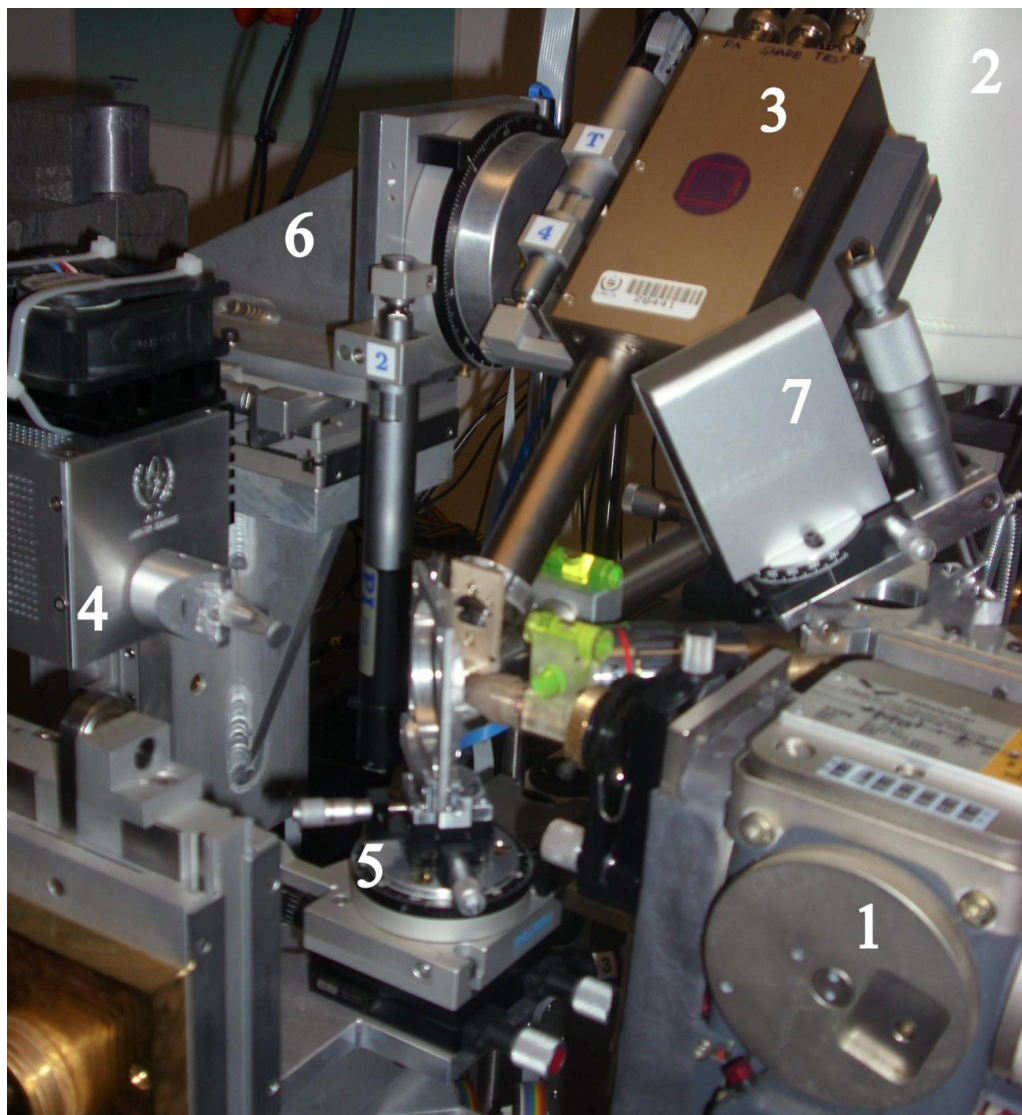
HASYLAB at DESY, DORIS III, beamline L

Spatial resolution in depth-scan: 15.2 μm (Cu-K α) and 14.3 μm (Zn-K α)

Reconstruction of multi-layer Zn/Cu standard

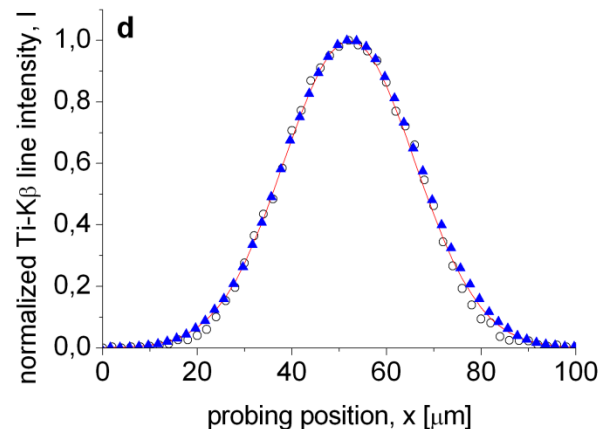
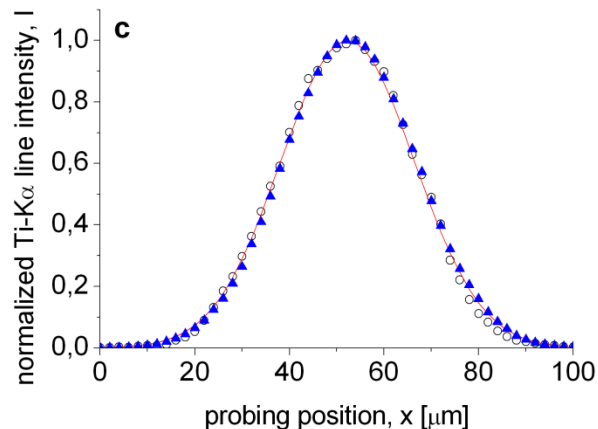
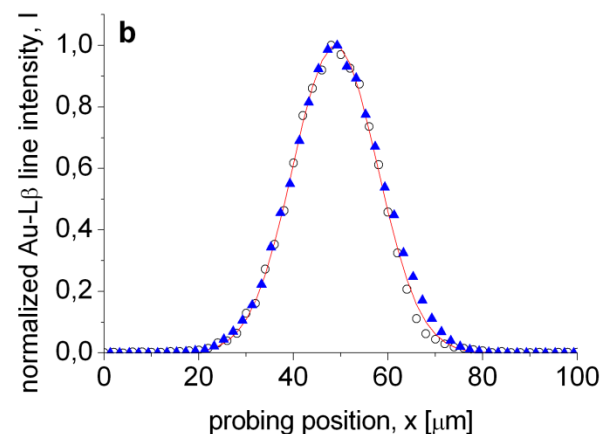
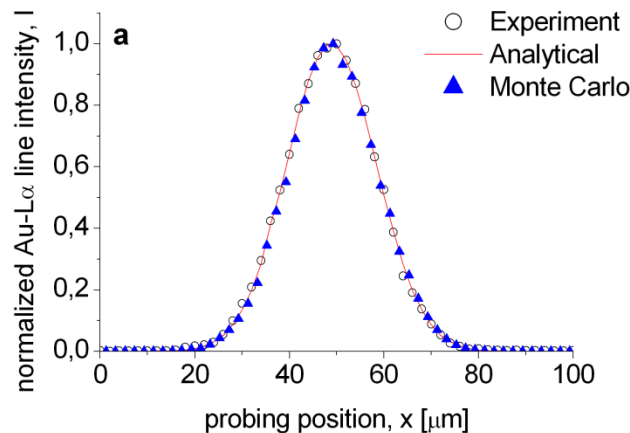
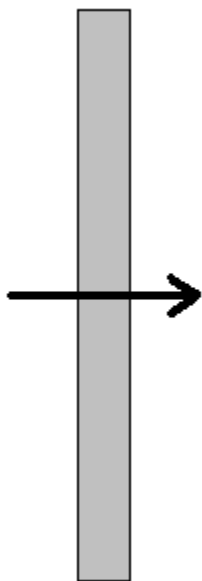


Confocal XRF spectrometer in the IAEA lab



Mateusz Czyzycki *et. al.*, Joint ICTP-IAEA Workshop on Advances in X-ray Instrumentation for Cultural Heritage Applications, 13-17 July 2015, Trieste, Italy

Mono-layers of high-Z matrix (1)

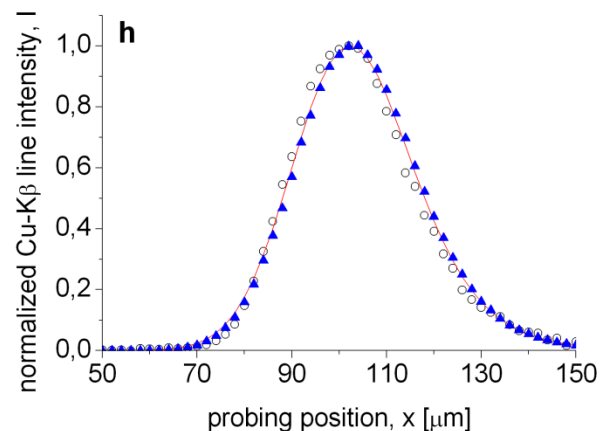
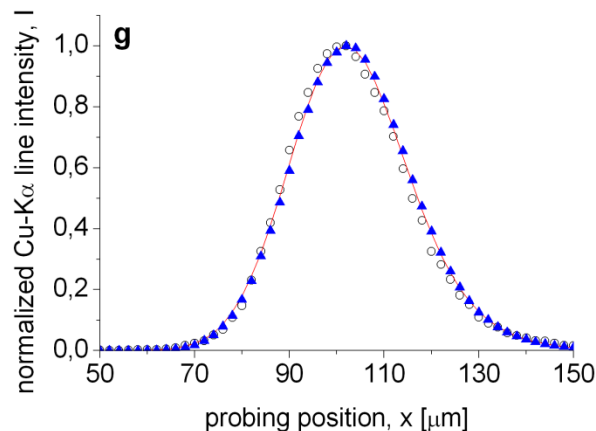
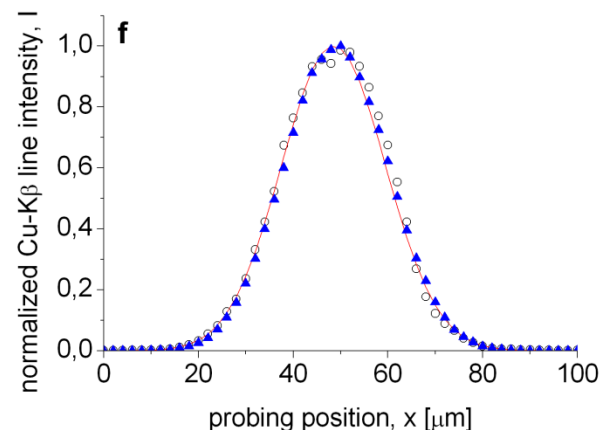
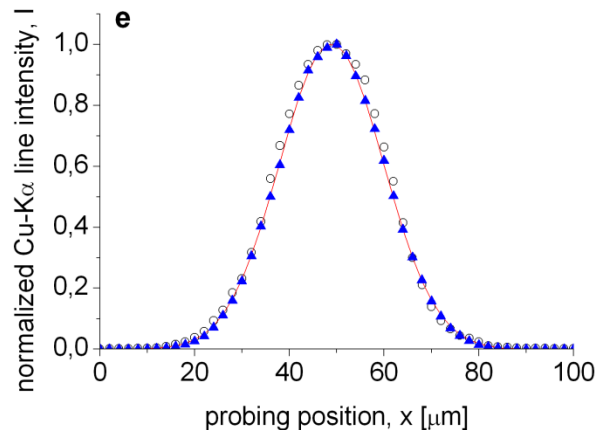
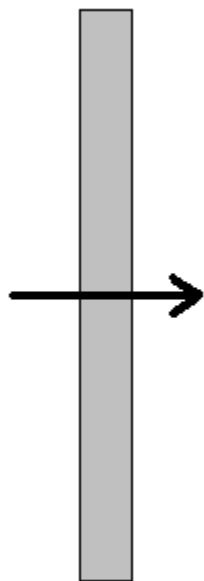


IAEA Seibersdorf

a,b – Au foil, 0,02 μm

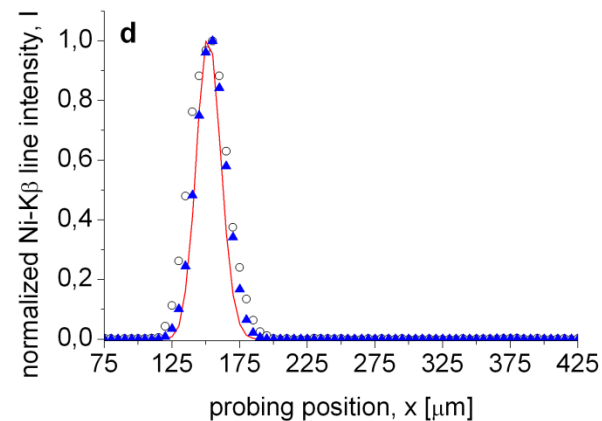
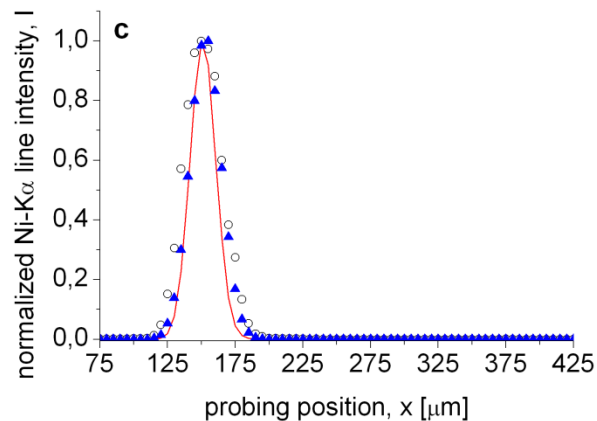
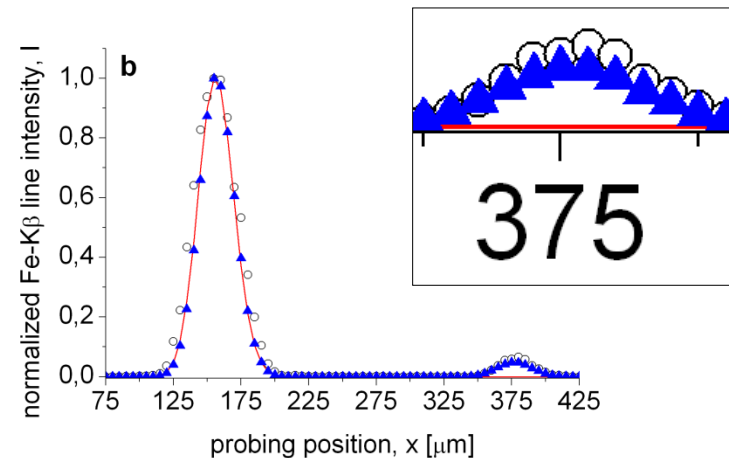
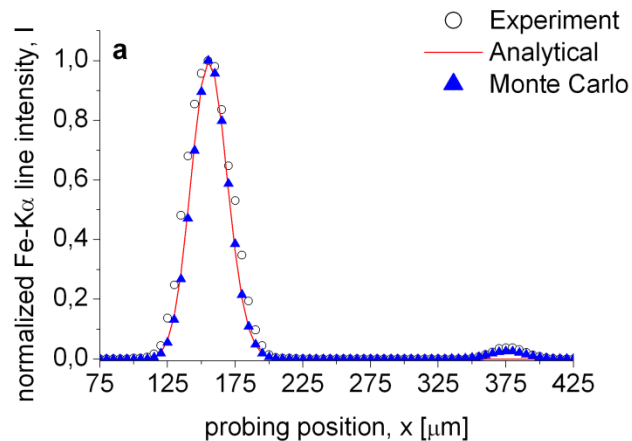
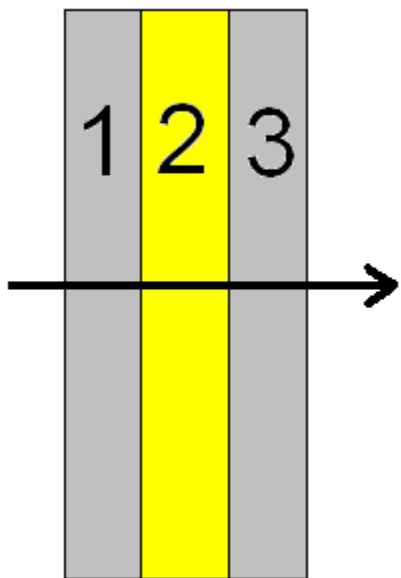
c,d – Ti foil, 6 μm

Mono-layers of high-Z matrix (2)



IAEA Seibersdorf e,f – Cu foil, 7 μm g,h – Cu sheet, 2 mm

Three-layer alloy standard



#1 i #3 – Fe_{0.64}Ni_{0.36} alloy foil, 25 μ m

#2 – (C₃H₆)_n foil, 220 μ m

Conclusion

Confocal μ XRF spectroscopy can be successfully used to discover the elemental composition of materials studied (in particular multi-layers).

Monte Carlo simulation is a reliable tool for the simulation of scanning confocal μ XRF experiments and for the qualitative and quantitative interpretation of experimental results.

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